

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Sato et al.
Appl. No.	:	10/540,056
Filed	:	June 22, 2005
For	:	POSITIVE RESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN
Examiner	:	Chu, John S.Y.
Group Art Unit	:	1795

AMENDMENT AND RESPONSE TO OFFICE ACTION**Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **March 9, 2009**, please consider the following amendments and remarks.

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Summary of Interview begins on page 4 of this paper.

Remarks begin on page 5 of this paper.